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# Quantitative Structure-Retention Relationship Study of Gas Chromatographic Retention Indices for Halogenated Compounds

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# Quantitative Structure-Retention Relationship Study of Gas Chromatographic Retention Indices for Halogenated Compounds<sup>#</sup>

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#### Abstract

**Motivation.** A high interest in predicting physical, chemical, and biological properties of halogenated compounds is generated by the urgent need to develop alternatives to chlorofluorocarbons, new compounds with low ozone depletion potential and a low global warming potential. Quantitative structure–retention relationships (QSRR) for halogenated compounds can be used to predict gas chromatographic retention indices by using theoretical descriptors computed from the chemical structure.

**Method**. QSRR models for the gas chromatographic retention indices of 207 halogenated compounds are established with the CODESSA (Comprehensive Descriptors for Structural and Statistical Analysis) program.

**Results.** The best results are obtained with a group of QSRR models with six structural descriptors, with a correlation coefficient between 0.994 and 0.993 and a leave-one-out cross-validation correlation coefficient between 0.992 and 0.991. All QSRR models contain the Kier and Hall connectivity index  ${}^{1}\chi^{\nu}$ , the number of F atoms NoF, and the gravitation index for all pairs of atoms G<sub>1</sub>. A fourth descriptor comes from the class of charged-partial surface area indices, while the remaining two descriptors are related to the number of I or Br atoms, bond order, or Randić connectivity index  ${}^{1}\chi$ .

**Conclusions**. QSRR models developed with CODESSA allow accurate computation of the gas chromatographic retention indexes of halogenated compounds using simple constitutional, topological, geometric, electrostatic and quantum descriptors that can be computed with standard quantum chemistry packages.

Keywords. Quantitative structure-retention relationships; halogenated organic compounds; CODESSA; gas chromatographic retention indices.

# **1 INTRODUCTION**

Halogen-containing organic compounds are an important class of chemicals, with numerous industrial and laboratory applications. They are used as solvents, plastics, anesthetics, foaming agents, refrigerants, and pesticides. Bromochlorofluorocarbons are used as fire extinguishing

<sup>#</sup> Dedicated on the occasion of the 70<sup>th</sup> birthday to Professor Alexandru T. Balaban.

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agents. Fluoro–compounds are extensively investigated as contrast agents in X–ray and MRI, and for use as antihypoxic agents in surgical and liquid ventilation procedures. On the other hand, the use of chlorofluorocarbons (CFCs) has damaging effects on the stratospheric ozone layer, and all halogenated compounds have an important contribution in global warming by the green house effect, and halogenated organic compounds are widespread pollutants of surface and underground water. A high interest in predicting physical, chemical, and biological properties of halogenated compounds is generated by the urgent need to develop alternatives to CFCs, new compounds with low ozone depletion potential and a low global warming potential. The identification of halogenated compounds can be made with the method of gas chromatographic peak comparison with a standard sample of the each compound. Because samples of pure compounds are not always available it is important to develop quantitative structure–retention relationships (QSRR) that can efficiently predict retention parameters by using theoretical descriptors computed from the chemical structure.

Chromatographic retention is a physical phenomenon that is primarily dependent on the interactions between the solute and the stationary phase. Molecular group contribution methods are widely employed to estimate gas chromatographic retention parameters [1-3]. The difficulty of this approach is represented by the definition of a consistent set of groups and by the necessity to compute the contribution of each group from a statistically significant number of molecules where the respective group is present. This method is limited to molecules containing only the groups presented in the calibration set of molecules. Also, some group contribution schemes are not comprehensive enough to cover multiple substitutions of functional groups.

With the aid of QSRR the interactions associated with this phenomenon can be related to the constitutional, molecular graph (topological), geometrical, electrostatic, and quantum descriptors of the molecules. Gas chromatographic QSRR models have been successfully developed for a large number of compound classes: alkanes [4–6], alkenes [4,7], alkylbenzenes [8], polycyclic aromatic hydrocarbons [9], various hydrocarbons from naphthas [10], various aromatic compounds [11], alkanes, alkenes, alcohols, esters, ketones [12], monoterpenes, di– and tricyclic methyl esters and alcohols, and monocyclic ketones and alcohols [13], chlorinated alkanes [14], chlorinated benzenes [15], chlorinated dibenzodioxins [16], polychlorinated biphenyls [17,18], polyhalogenated biphenyls [19], polychlorinated dibenzofurans [18,20], pyrazines [21], diverse drug compounds [22], odor–active aliphatic compounds with oxygen–containing functional groups [23], stimulants and narcotics [24], anabolic steroids [25], sulfur vesicants [26], diverse organic compounds [27].

Integrated strategies for generating structure–property models were proposed along the years. These approaches use various programs that allow the rapid input of the chemical structures of the molecules under study, geometry optimization with molecular mechanics and quantum methods, calculation of a large set of descriptors, generation and validation of statistical structure–property models. The ADAPT program [28] is designed to compute the 3–dimensional structure of the

investigated chemical compounds, and to use constitutional, geometric and quantum information in order to generate a large number of descriptors. Various statistical models such as Multi–Linear Regression (MLR) or neural networks are tested in order to obtain the best structure–property model. ADAPT was extensively applied to the estimation of gas chromatographic retention indices of various classes of organic compounds [7,10,17,19,21–26]. Other software programs that can compute a large set of descriptors and then use them in various QSAR models are OASIS (Optimized Approach based on Structural Indices Selection) [29], PRECLAV (PRoperty Evaluation by CLAss Variables) [30], and CODESSA (Comprehensive Descriptors for Structural and Statistical Analysis) [31–33].

The CODESSA program developed by Katritzky and coworkers [31–33] implements a structure–property approach which uses about 500 structural parameters representing constitutional, topological, geometrical, electrostatic and quantum descriptors of the chemical compounds. The computed structural descriptors are used to develop models of the investigated property. CODESSA was successfully employed in structure–property studies concerning the prediction of gas chromatographic retention indices [27], normal boiling temperatures [34,35], melting temperatures for substituted benzenes [36], physical properties of substituted pyridines [37], solubility of gases and vapors in water [38], solvent polarity scale [39], polymer glass transition temperatures [40], critical micelle concentration [41], normal boiling temperatures of organic compounds containing halogen, oxygen, and sulfur [42], liquid viscosity of organic compounds [43]. The goal of the present work is to employ computer–assisted methods to develop QSRR equations relating structural features of various halogenated compounds to their experimental gas chromatographic retention indices.

## 2 MATERIALS AND METHODS

The QSRR models for the estimation of the gas chromatographic retention indices of various halogenated compounds are established in the following five steps: molecular structure input and generation of the files containing the chemical structures stored in a computer–readable format; quantum mechanics geometry optimization with a semi–empirical method; structural descriptors computation; structural descriptors selection; structure–retention models generation with the multi–linear regression method.

GC Retention Data. Retention indices (*RI*) of 207 halogenated aliphatic and alicyclic compounds were taken from the literature [44], and are presented in Table 1. The chromatograms were recorded on a Hewlett–Packard Model 5890A gas chromatograph equipped with flame ionization detector, with the following operating conditions: fused–silica 50 m × 0.2 mm capillary column coated with methyl silicone, carrier gas (nitrogen) flow velocity 10 cm/s, injection port and detector temperatures 270 °C. The temperature program comprised an initial isothermal period of 5

min at 40 °C, followed by a temperature increase of 2 °C/min up to 200 °C, and a final isothermal stage at this temperature. The retention indices of the halogenated compounds were computed using 1–bromoalkanes as standards. A good linear relationship between retention time and carbon number of the 1–bromoalkanes was observed, except for bromomethane and bromoethane. If the retention time of any compound was smaller than that of bromomethane, the retention index for that compound was calculated by considering methane as standard compound.

Table 1. Structure and Gas Chromatographic Retention Indices of 207 Halogenated Compounds

Nr.	Compound	RI	Nr.	Compound	RI
1	Bromotrichloromethane	434	47	1-Bromo-2-chloroethane	390
2	Tetrabromomethane	726	48	1,1-Dibromoethane	406
3	Dichlorodifluoromethane	0	49	1,2-Dibromoethane	465
4	Trichlorofluoromethane	158	50	1,2-Dichloroethane	315
5	Chloropicrin	443	51	Dichloromethyl methyl ether	340
6	Tetrachloromethane	338	52	1,1-Difluoroethane	0
7	Tetraiodomethane	1497	53	1,2-Diiodoethane	682
8	Bromodichloromethane	374	54	Bromoethane	200
9	Chlorodibromomethane	458	55	Chloroethane	110
10	Bromoform	546	56	Chloromethyl methyl ether	226
11	Chloroform	292	57	Iodoethane	284
12	Iodoform	905	58	Octachloropropane	1225
13	Bromochloromethane	284	59	1,1,1,2,3,3,3-Heptachloropropane	1034
14	Dibromomethane	363	60	(Z)-1,2,3-Trichloropropene	532
15	Dichloromethane	206	61	(E)-1,2,3-Trichloropropene	573
16	Diiodomethane	582	62	Methyltrichloroacetate	585
17	Bromomethane	100	63	1,1,2,3,3-Pentachloropropane	787
18	Iodomethane	200	64	1,1,3-Trichloroacetone	613
19	1,1,1-Trichloro-2,2,3-trifluoroethane	210	65	2,3-Dibromopropene	532
20	1,1,2-Trichloro-1,2,2-trifluoroethane	211	66	1,1-Dichloropropene	327
21	Trichloroacetonitrile	351	67	(Z)-1,3-Dichloropropene	406
22	Tetrachloroetylene	481	68	(E)-1,3-Dichloropropene	425
23	1,2-Difluoro-1,1,2,2-tetrachloroethane	387	69	2,3-Dichloropropene	367
24	Hexachloroethane	744	70	Methyl dichloroacetate	513
25	Tribromoethylene	637	71	1,1,1,2-Tetrachloropropane	596
26	Pentabromoethane	1172	72	1,1,2,3-Tetrachloropropane	682
27	Trichloroethylene	372	73	1,2,2,3-Tetrachloropropane	639
28	Trichloroacetaldehyde	382	74	3-Bromo-1-propene	284
29	Pentachloroethane	641	75	(Z)-1-Bromo-1-propene	265
30	(Z)-1,2-Dibromoethylene	410	76	( <i>E</i> )-1-Bromo-1-propene	275
31	(E)-1,2-Dibromoethylene	438	77	Bromoacetone	433
32	1,2-Dibromo-1,1-dichloroethane	689	78	Methyl bromoacetate	490
33	<i>rac</i> -1,2-Dibromo-1,2-dichloroethane	744	79	3-Chloro-1,2-dibromopropane	734
34	<i>meso</i> -1,2-Dibromo-1,2-dichloroethane	747	80	1,2,3-Tribromopropane	815
35	1,1,2,2-Tetrabromoethane	929	81	3-Chloro-1-propene	208
36	Chloroacetonitrile	345	82	(Z)-1-Chloro-1-propene	194
37	1,1-Dichloroethylene	202	83	( <i>E</i> )-1-Chloro-1-propene	203
38	(E)-1,2-Dichloroethylene	234	84	Chloroacetone	310
39	1,1,1,2-Tetrachloroethane	513	85	Methyl chloroacetate	431
40	1,1,2,2-Tetrachloroethane	565	86	1,1,2-Trichloropropane	507
41	Bromoethylene	131	87	1,2,3-Trichloropropane	572
42	1,1,2-Tribromoethane	687	88	I-Bromo-3-chloropropane	521
43	Chloroethylene	50	89	1,2-Dibromopropane	515
44	Methylchloroformate	252	90	1,3-Dibromopropane	597
45	1,1,1-Trichloroethane	318	91	2,2-Dibromopropane	436
46	1,1,2-Trichloroethane	433	92	1,2-Dichloropropane	362

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Table 1. (Continued)							
Nr.	Compound	RI	Nr.	Compound	RI		
93	1,3-Dichloropropane	441	149	2,2-Dimethyl-1,3-dichloropentane	554		
94	2,2-Dichloropropane	287	150	1-Bromopentane	500		
95	1-Bromopropane	300	151	2-Bromopentane	451		
96	2-Bromopropane	248	152	2-Bromo-2-methylbutane	416		
97	1-Chloropropane	218	153	1-Chloropentane	423		
98	2-Chloropropane	177	154	1-Chloro-3-methylbutane	389		
99	Chloromethyl ethyl ether	315	155	2-Chloro-2-methylbutane	338		
100	1-Iodopropane	385	156	1-Iodopentane	590		
101	2-Iodopropane	337	157	1-Iodo-3-methylbutane	547		
102	Hexachloro-1,3-butadiene	885	158	2-Iodo-2-methylbutane	509		
103	Ethyl trifluoroacetate	209	159	Tetradecafluoro-2-methylpentane	0		
104	meso-1,2,3,4-Tetrabromobutane	1195	160	Tetradecafluorohexane	0		
105	(Z)-1,3-Dichloro-2-butene	493	161	α-BHC	1356		
106	( <i>E</i> )-1,3-Dichloro-2-butene	509	162	β-ΒΗC	1388		
107	(Z)-1,4-Dichloro-2-butene	553	163	γ-BHC	1434		
108	( <i>E</i> )-1,4-Dichloro-2-butene	573	164	δ-BHC	1454		
109	3.4-Dichloro-1-butene	451	165	3-Bromocyclohexene	663		
110	3-Bromo-1-butene	338	166	cis-1.4-Dichlorocyclohexane	775		
111	4-Bromo-1-butene	378	167	<i>trans</i> -1.4-Dichlorocyclohexane	741		
112	( <i>E</i> )-1-Bromo-2-butene	416	168	Bromocyclohexane	645		
113	(Z)-2-Chloro-2-butene	278	169	Chlorocyclohexane	559		
114	( <i>E</i> )-2-Chloro-2-butene	305	170	Iodocvclohexane	738		
115	3-Chloro-1-butene	259	171	2,3-Dibromo-2,3-dimethylbutane	726		
116	1-Chloro-2-methyl-1-propene	297	172	1,6-Dibromohexane	965		
117	3-Chloro-2-methyl-1-propene	303	173	1-Bromohexane	600		
118	1,2-Dibromobutane	622	174	1-Bromo-4-methylpentane	564		
119	1,3-Dibromobutane	648	175	1-Chlorohexane	524		
120	1,4-Dibromobutane	725	176	2-Chlorohexane	476		
121	rac-2,3-Dibromobutane	581	177	3-Chlorohexane	476		
122	meso-2,3-Dibromobutane	593	178	1-Iodohexane	692		
123	1,2-Dichlorobutane	466	179	Tetradecafluoromethylcyclohexane	68		
124	1,3-Dichlorobutane	490	180	Hexadecafluoroheptane	30		
125	1,4-Dichlorobutane	558	181	Bromocycloheptane	779		
126	2,2-Dichlorobutane	404	182	Chlorocycloheptane	699		
127	2,3-Dichlorobutane	428	183	1-Bromoheptane	700		
128	1,2-Dichloroethyl ethyl ether	526	184	2-Bromo-2-methylhexane	604		
129	2,2'-Dichlorodiethyl ether	632	185	2-Bromo-2,4-dimethylpentane	565		
130	1-Bromobutane	400	186	1-Chloroheptane	626		
131	2-Bromobutane	356	187	2-Chloroheptane	572		
132	2-Bromo-2-methylpropane	301	188	1-Iodoheptane	791		
133	2-Bromoethyl ethyl ether	479	189	1,8-Dibromooctane	1170		
134	1-Chlorobutane	320	190	1,8-Dichlorooctane	987		
135	2-Chlorobutane	284	191	1-Bromooctane	800		
136	1-Chloro-2-methylpropane	291	192	1-Bromo-2-ethylhexane	753		
137	2-Chloro-2-methylpropane	220	193	1-Chlorooctane	720		
138	1-Iodobutane	483	194	1-Iodooctane	892		
139	2-Iodo-2-methylpropane	381	195	1-Bromononane	900		
140	Hexachlorocyclopentadiene	999	196	1-Chlorononane	820		
141	1,1,1,5,5,5-Hexafluoropentan-2,4-dione	208	197	1-Chloroadamantane	945		
142	Bromocyclopentane	525	198	2-Chloroadamantane	989		
143	1-Bromo-3-methyl-2-butene	517	199	1,10-Dibromodecane	1374		
144	Chlorocyclopentane	449	200	1,10-Dichlorodecane	1192		
145	1,4-Dibromopentane	772	201	1-Bromodecane	1000		
146	1,5-Dibromopentane	836	202	I-Chlorodecane	919		
147	2,4-Dibromopentane	677	203	I-Bromoundecane	1100		
148	1,5-Dichloropentane	676	204	I-Chloroundecane	1019		

	Table 1. (Continued)	
Nr.	Compound	RI
205	1,12-Dibromododecane	1579
206	1-Bromododecane	1200
207	1-Bromotridecane	1300

**Molecular Structure Input**. Three–dimensional models of the 207 halogenated compounds were generated with HyperChem [45] and optimized with the MM+ molecular mechanics program implemented in HyperChem. The HyperChem files were exported in a format suitable for the AMPAC [46] program.

**Quantum Mechanics Computations**. The geometry optimization was performed on a Pentium 200 MHz with the semiempirical quantum method AM1 [47] using the AMPAC 5.0 program [46]. The following set of key words were used in all quantum computations: AM1 PRECISE VECTORS BONDS PI KPOLAR ENPART.

**Structural Descriptors Generation**. The HyperChem structure files and the AMPAC output files were used by the CODESSA program [48] to compute a total of 518 structural descriptors. For certain compounds it was not possible to compute some descriptors and in the subsequent computations we have assumed a zero value in all such cases. CODESSA computes five classes of structural descriptors: constitutional (number of various types of atoms and bonds, number of rings, molecular weight, etc.); topological (Wiener index, Randić connectivity indices, Kier and Hall connectivity indices, Kier shape indices, information content indices, etc.); geometrical (gravitation indices, moments of inertia, molecular volume and surface area, etc.); electrostatic (when atomic charges are computed on the basis of atomic electronegativity: minimum and maximum partial charges, Fukui reactivity indices, dipole moment, HOMO and LUMO energies, etc.). The definition of all descriptors used in the present study can be found in the CODESSA Reference and User's Manuals.

**Structural Descriptors Selection**. A selection of descriptors is accomplished with the aim to reduce the pool of descriptors by eliminating those that satisfy the following conditions: (*a*) the descriptor has a constant value for all molecules investigated; (*b*) in the monoparametric correlation with the gas chromatographic retention indices the descriptor has a squared correlation coefficient lower than 0.1; (*c*) in the monoparametric correlation the descriptor has a *t*-test value lower than 0.1; (*d*) in the monoparametric correlation the descriptor has a F-test value lower than 1; (*e*) the descriptor has an intercorrelation coefficient higher than 0.990 with another descriptor, and the second one has a higher squared correlation coefficient in the monoparametric correlation with the retention index. In this phase 298 descriptors were removed, and 220 descriptors were selected for the generation of the multiparametric correlations.

Structure–Retention Models Generation. The development of multilinear regression (MLR)

QSRR models with CODESSA comprises the following steps: (*a*) all biparametric regression equations are computed for pair of descriptors with an intercorrelation coefficient lower than 0.8; (*b*) the 10 best pairs of descriptors in biparametric correlations are selected for the development of multiparametric equations; (*c*) to an MLR model containing *n* descriptors a new descriptor is added to generate a model with n + 1 descriptors if the new descriptor is not significantly correlated with the previous *n* descriptors (intercorrelation coefficient lower than 0.8). Step (*c*) is repeated until MLR models with a certain maximum number of descriptors were obtained.

Table 2. Notation of the CODESSA Descript	tors Involved in the QSRR Ec	quations Presented in '	Table 3
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Descriptor	Notation	Type <sup>a</sup>
Number of H atoms	NoH	Ċ
Number of F atoms	NoF	С
Relative number of F atoms	RNoF	С
Number of Br atoms	NoBr	С
Relative number of Br atoms	RNoBr	С
Number of I atoms	NoI	С
Relative number of I atoms	RNoI	С
Gravitation index (all bonds)	G <sub>2</sub>	С
Gravitation index (all pairs)	$G_1$	С
Topographic electronic index (all pairs) (electrostatic)	Te	Е
Total molecular surface area (electrostatic)	TMSA <sub>e</sub>	Е
Weighted PNSA (PNSA1*TMSA/1000) (electrostatic)	WNSA1 <sub>e</sub>	Е
Difference in CPSAs (PPSA2–PNSA2) (electrostatic)	DPSA2 <sub>e</sub>	Е
Difference in CPSAs (PPSA3–PNSA3) (electrostatic)	DPSA3 <sub>e</sub>	Е
Fractional PNSA (PNSA3/TMSA) (electrostatic)	FNSA3 <sub>e</sub>	Е
Weighted PNSA (PNSA3*TMSA/1000) (electrostatic)	WNSA3 <sub>e</sub>	Е
XY Shadow	XYs	G
Molecular volume	V	G
Molecular surface area	S	G
Final heat of formation	$H_{f}$	Q
Total molecular surface area (quantum)	TMSAq	Q
Atomic charge weighted PNSA (quantum)	PNSA3 <sub>q</sub>	Q
Weighted PPSA (PPSA3*TMSA/1000) (quantum)	WPSA3 <sub>q</sub>	Q
Maximum $\pi - \pi$ bond order	$BO_{\pi\pi \max}$	Q
Total molecular two-center resonance energy / number of atoms	MTCRE	Q
$\alpha$ polarizability (computed from the dipole moment)	α	Q
Minimum one-electron reactivity index for a F atom	OERI <sub>F min</sub>	Q
Minimum net atomic charge for a I atom	Q <sub>I min</sub>	Q
Wiener index	W	T
Randić connectivity index (order 1)	$^{1}\chi$	Т
Randić connectivity index (order 2)	$2^{2} \chi$	Т
Randić connectivity index (order 3)	$3^{\prime}\gamma$	Т
Kier and Hall connectivity index (order 0)	$\sqrt[0]{\gamma^{\nu}}$	Т
Kier and Hall connectivity index (order 1)	$\frac{1}{2}v^{\nu}$	Ť
Kier and Hall connectivity index (order 3)	${}^{3}\tilde{\gamma}^{\nu}$	Ť

<sup>*a*</sup> The descriptor type is coded with C for constitutional, E for electrostatic, G for geometric, Q for quantum, and T for topological

## **3 RESULTS AND DISCUSSION**

Table 2 presents the notation of the 35 descriptors involved in the QSRR models developed for the gas chromatographic retention indices of halogenated compounds. The descriptor type is coded

with C for constitutional, E for electrostatic, G for geometric, Q for quantum, and T for topological.

the Gas Chromatographic Retention Indices of 207 Halogenated Compounds							
Eq.	Descriptors	Туре	r	$r_{\rm cv}$	S	F	
1	$^{1}\chi^{\nu}$	Т	0.887	0.885	143	758	
2	$^{0}\chi^{\nu}$	Т	0.854	0.850	161	553	
3	α	Q	0.772	0.765	197	302	
4	$^{3}\chi^{\nu}$	Т	0.751	0.744	205	265	
5	TMSA <sub>q</sub>	Q	0.722	0.715	215	223	
6	V	G	0.705	0.693	220	202	
7	XYs	G	0.696	0.689	223	193	
8	S	G	0.689	0.682	225	186	
9	TMSA <sub>e</sub>	Е	0.684	0.677	226	180	
10	WPSA3 <sub>q</sub>	Q	0.659	0.652	233	158	
11	${}^{0}\chi^{\nu}$ NoF	TC	0.956	0.955	91	1084	
12	$^{0}\chi^{\nu}$ RNoF	TC	0.950	0.948	97	952	
13	$^{1}\chi^{\nu}$ NoF	TC	0.946	0.945	101	873	
14	$^{1}\chi^{\nu}$ H <sub>f</sub>	TQ	0.943	0.941	104	816	
15	$^{1}\chi^{\nu}$ RNoF	TC	0.942	0.939	105	801	
16	$^{0}\chi^{\nu}$ H <sub>f</sub>	TQ	0.940	0.938	106	777	
17	$^{1}\chi^{\nu}$ W	TT	0.937	0.934	109	728	
18	$^{1}\tilde{\chi}^{\nu}$ T <sub>e</sub>	TE	0.933	0.929	112	680	
19	${}^{0}\chi^{\nu}$ OERI <sub>F min</sub>	TQ	0.932	0.923	113	673	
20	$^{0}\chi^{\nu}^{2}\chi$	TT	0.930	0.925	114	653	
21	$\frac{1}{\gamma^{\nu}} \operatorname{NoF} G_1$	TCC	0.975	0.974	69	1314	
22	$\frac{1}{2}$ NoF G <sub>2</sub>	TCC	0.971	0.970	74	1130	
23	$\frac{1}{\gamma^{\nu}}$ NoF WNSA1	TCE	0.971	0.970	74	1122	
24	$^{1}\gamma^{\nu}$ NoF NoH	TCC	0.969	0.967	78	1024	
25	$^{0}\chi^{\nu}$ NoF $^{3}\chi$	ТСТ	0.967	0.964	79	975	
26	$^{1}\gamma^{\nu}$ NoF G <sub>1</sub> DPSA3.	TCCE	0.987	0.984	51	1865	
27	$^{1}\gamma^{\nu}$ NoF G <sub>1</sub> WNSA3.	TCCE	0.987	0.984	51	1836	
28	$^{1}\chi^{\nu}$ NoF G. $^{1}\chi$	ТССТ	0.985	0 984	53	1704	
29	$\frac{1}{2}$ NoF G. DPSA2	TCCE	0.985	0.983	54	1629	
30	$\chi^{\nu}$ NoF G, PNSA3	TCCO	0.983	0.982	57	1481	
31	$\lambda^{\mu}$ NoF G, DPSA3 NoBr	TCCFC	0.991	0.989	43	2093	
32	$\lambda^{1} \alpha^{\nu} N_{0} F G DPS A 2 PN_{0} Pr$	TCCEC	0.990	0.989	44	2020	
32	$\chi^{1}$ NoF G WNSA2 NoBr	TCCEC	0.990	0.988		1990	
34	$\chi$ Nor $G_1$ WINSAS <sub>e</sub> NODI	TCCEC	0.990	0.900	45	1032	
25	$\chi$ INOF $O_1$ WINSAS <sub>e</sub> KINODI	TCCEC	0.990	0.988	45	1932	
26	$\chi$ NOF $G_1$ DPSA3 <sub>e</sub> NOI	TCCECT	0.990	0.988	45 26	2524	
27	$\chi$ NOF G <sub>1</sub> DPSA3 <sub>e</sub> NOF $\chi$	TCCECT	0.994	0.992	26	2334	
20	$\chi^2$ NOF G <sub>1</sub> DPSA3 <sub>e</sub> NOBI BO <sub><math>\pi\pi</math> max</sub>	TCCEUQ	0.995	0.992	20	2407	
38	$\chi$ NoF G <sub>1</sub> WNSA3 <sub>e</sub> NoI $\chi$	TCCETC	0.993	0.992	3/	2326	
39	$\chi^{\prime}$ NoF G <sub>1</sub> DPSA3 <sub>e</sub> NoI MTCRE	TCCETQ	0.993	0.991	3/	2311	
40	$\chi$ NoF G <sub>1</sub> DPSA3 <sub>e</sub> RNoBr BO <sub><math>\pi\pi</math> max</sub>	TCCECQ	0.993	0.991	38	2284	
41	$\chi$ NoF G <sub>1</sub> FNSA3 <sub>e</sub> NoI $\chi$	TCCTEC	0.993	0.991	38	2267	
42	$^{1}\chi^{v}$ NoF G <sub>1</sub> WNSA3 <sub>e</sub> Q <sub>I min</sub> $^{1}\chi$	TCCETQ	0.993	0.991	38	2266	
43	$\chi^{\prime}$ NoF G <sub>1</sub> WNSA3 <sub>e</sub> NoBr BO <sub><math>\pi\pi</math> max</sub>	TCCECQ	0.993	0.991	38	2246	
44	$\chi^{\nu}$ NoF G <sub>1</sub> WNSA3 <sub>e</sub> RNoI $\chi$	TCCETC	0.993	0.991	38	2232	
45	$^{1}\chi^{\nu}$ NoF G <sub>1</sub> FNSA3 <sub>e</sub> RNoI $^{1}\chi$	TCCTEC	0.993	0.991	38	2225	

Table 3. Statistical Indices r,  $r_{cv}$ , s, F, and Structural Descriptors Involved in the Multi– Linear Regression Equations Containing Up to Six Descriptors Developed to Compute the Gas Chromatographic Retention Indices of 207 Halogenated Compounds

The best multi-linear regression equations with up to six descriptors generated by CODESSA are presented in Table 3. For each equation we report the descriptors involved, their type, and the

statistical indices of the model, *i.e.* the correlation coefficient *r*, the leave–one–out cross–validation correlation coefficient  $r_{cv}$ , the standard deviation *s*, and the F–test value. An inspection of the best ten mono–parametric correlations reported in Table 3 Eqs. (1)–(10), shows that the Kier and Hall  ${}^{1}\chi^{\nu}$  and  ${}^{0}\chi^{\nu}$  indices, with r = 0.887 and r = 0.854, respectively, are by far the best descriptors surpassing the more complex electrostatic or quantum descriptors.

All best 10 bi–parametric correlations presented in Table 3 Eqs. (11)–(20) contain at least a topological index, either  ${}^{0}\chi^{\nu}$  or  ${}^{1}\chi^{\nu}$ . The second descriptor is NoF in Eqs. (11) and (13), RNoF in Eqs. (12) and (15), heat of formation H<sub>f</sub> in Eqs. (14) and (16), the minimum one–electron reactivity index for a F atom, OERI<sub>F min</sub>, in Eq. (19), the topographic electronic index T<sub>e</sub> in Eq. (18), or a second topological index, such as the Wiener index *W* in Eq. (17), or the Randić connectivity index  ${}^{2}\chi$ . The introduction of a second descriptor significantly improves the statistical indices of the QSRR model, such as in Eq. (11), when the use of  ${}^{0}\chi^{\nu}$  together with NoF gives r = 0.956,  $r_{cv} = 0.955$ , s = 91, and F = 1084.

A further improvement of the QSRR models is obtained by using three descriptors, as can be seen from the statistics of Eqs. (21)–(25), with *r* between 0.975 and 0.967, and the leave–one–out cross–validation correlation coefficient  $r_{cv}$  between 0.974 and 0.964. The importance of the Kier and Hall connectivity indices in the QSRR modeling of the retention indices for halogenated compounds is once again indicated by their presence in this group of equations, namely  ${}^{1}\chi^{\nu}$  in Eqs. (21)–(24) and  ${}^{0}\chi^{\nu}$  in Eq. (25). The second descriptor is NoF for all five QSRR models with three structural descriptors, indicating the particular behavior of F compared with the other halogens. The third descriptor brings some variation in these equations, showing that similar QSRR models can be obtained with different combinations of structural descriptors.

The best QSRR models with four descriptors, presented in Table 3 Eqs. (26)–(30), show a further improvement in the statistical indices, with *r* between 0.987 and 0.983, and  $r_{cv}$  between 0.984 and 0.982. For all these QSRR models the first three descriptors are identical with those from Eq. (21), namely  ${}^{1}\chi^{\nu}$ , NoF, and the gravitation index for all pairs of atoms G<sub>1</sub>. The fourth descriptor is either from the class of charged–partial surface area indices (CPSA) or the Randić connectivity index  ${}^{1}\chi$ . For the group of QSRR models with five descriptors, presented in Table 3 Eqs. (31)–(35), the statistical indices continue to improve, with *r* between 0.991 and 0.990, and  $r_{cv}$  between 0.989 and 0.988. Besides the three descriptors  ${}^{1}\chi^{\nu}$ , NoF, and G<sub>1</sub>, which are common for all these equations, the fourth one is from the CPSA class (DPSA3<sub>e</sub> or WNSA3<sub>e</sub>, both computed with atomic charges derived from electronegativity) and the fifth one is NoBr, RNoBr, or NoI. The QSRR models that contain DPSA3<sub>e</sub> are derived from Eq. (26), while those that contain WNSA3<sub>e</sub> are derived from Eq. (27).

For the ten QSRR models with six parameters presented in Table 3 Eqs. (36)–(45) the F index and leave-one-out cross-validation correlation coefficient have a maximum, and the r and s

statistical indices are improved when compared with those obtained for the MLR models with five structural descriptors, presented in Table 3 Eqs. (31)–(35). This group of QSRR models is very homogeneous from a statistical point of view, having *r* between 0.994 and 0.993,  $r_{cv}$  between 0.992 and 0.991, and standard deviation *s* between 36 and 38. This result clearly shows that starting with a large selection of structural descriptors it is possible to find several combinations of descriptors that provide models with similar good statistics. Moreover, owing to the errors in the experimental data, small statistical differences between QSRR equations are not significant, and it is almost impossible to select a "best" modeling equation in such cases. We present below the detailed QSRR Eqs. (36)–(45) containing each six theoretical descriptors:

$$\begin{split} RI &= -247.4(\pm 10.2) + 115.7(\pm 5.2)^{1}\chi^{v} - 105.5(\pm 2.5)\text{NoF} + 0.06(\pm 0.003)\text{G}_{1} + 9.9(\pm 0.7)\text{DPSA}_{3} + 83.0(\pm 7.4)\text{NoI} + 58.5(\pm 5.5)^{1}\chi \end{split} (36) \\ n &= 207 \ r = 0.994 \ r_{cv} = 0.992 \ s = 36 \ F = 2534 \ \text{outliers:} 36, 58 \\ RI &= -243.7(\pm 9.9) + 177.1(\pm 2.7)^{1}\chi^{v} - 85.5(\pm 1.6)\text{NoF} + 0.07(\pm 0.003)\text{G}_{1} + 7.3(\pm 0.5)\text{DPSA}_{3}_{c} \\ - 31.6(\pm 2.9)\text{NoBr} + 62.7(\pm 6.9) \text{BO}_{\pi\pi\,\text{max}} (37) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.992 \ s = 36 \ F = 2467 \ \text{outliers:} 7, 21, 161 \\ RI &= -176.9(\pm 7.9) + 107.2(\pm 5.2)^{1}\chi^{v} - 112.6(\pm 2.6)\text{NoF} + 0.06(\pm 0.003)\text{G}_{1} - 30.7(\pm 2.2)\text{WNSA}_{3}_{c} + 59.7(\pm 5.7)^{1}\chi + 76.6(\pm 7.6)\text{NoI} (38) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.992 \ s = 37 \ F = 2326 \ \text{outliers:} 36, 140 \\ RI &= -504.2(\pm 28.1) + 163.1(\pm 2.5)^{1}\chi^{v} - 95.0(\pm 2.0)\text{NoF} + 0.06(\pm 0.003)\text{G}_{1} + 11.2(\pm 0.7)\text{DPSA}_{2} + 79.6(\pm 7.7)\text{NoI} - 24.9(\pm 2.7)\text{MTCRE} (39) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.991 \ s = 37 \ F = 2311 \ \text{outliers:} 7, 58 \\ RI &= -230.3(\pm 10.5) + 169.8(\pm 2.8)^{1}\chi^{v} - 86.1(\pm 1.7)\text{NoF} + 0.07(\pm 0.003)\text{G}_{1} + 7.3(\pm 0.5)\text{DPSA}_{3}_{c} \\ -225.6(\pm 23.4)\text{RNoBr} + 60.4(\pm 7.2)\text{BO}_{\pi\pi\,\text{max}} (40) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.991 \ s = 38 \ F = 2284 \ \text{outlier:} 7 \\ RI &= -277.6(\pm 12.9) + 120.8(\pm 5.6)^{1}\chi^{v} - 108.3(\pm 2.7)\text{NoF} + 0.06(\pm 0.003)\text{G}_{1} + 7.8(\pm 5.4)^{1}\chi - 287.3(\pm 214.4)\text{FNSA}_{3} + 84.4(\pm 8.0)\text{NoI} (41) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.991 \ s = 38 \ F = 2267 \ \text{outlier:} 36 \\ RI &= -175.2(\pm 8.0) + 108.5(\pm 5.3)^{1}\chi^{v} - 111.7(\pm 2.6)\text{NoF} + 0.06(\pm 0.003)\text{G}_{1} - 29.9(\pm 2.2)\text{WNSA}_{3} + 59.1(\pm 5.8)^{1}\chi + 1457.5(\pm 149.7)\text{Q}_{1} \text{min} (42) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.991 \ s = 38 \ F = 2267 \ \text{outlier:} 36 \\ RI &= -191.4(\pm 9.1) + 171.2(\pm 2.9)^{1}\chi^{v} - 90.3(\pm 1.9)\text{NoF} + 0.07(\pm 0.003)\text{G}_{1} - 23.1(\pm 1.7)\text{WNSA}_{3} - 30.8(\pm 3.1)\text{NoF} + 61.1(\pm 7.3)\text{BO}_{\pi\pi\,\text{max}} (43) \\ n &= 207 \ r = 0.993 \ r_{cv} = 0.991 \ s = 38 \ F = 2232 \ \text{outlier:} 36 \\ RI &= -173.4(\pm 8.0) + 111.0(\pm 5.3)^{1}\chi^{v} - 110$$

In the above MLR equations, after each coefficient of a QSRR model we have provided its 95% confidence range. For each QSRR model with six structural descriptors we have identified the compounds that have absolute residuals greater than 3 standard deviations. Such compounds, identified for each equation with the corresponding number from Table 1, are considered to be outliers that cannot be modeled with the MLR model. In Table 4 we present the residual values for the entire group of outliers from Eqs. (36)–(45), namely compounds 7, 21, 36, 58, 140, and 161. A possible explanation for their large residuals is an error in the experimental *RI* or that the appropriate descriptors were not included in the QSRR models. No specific reason could be determined to explain why these six compounds act as outliers. Halogens are particularly difficult to characterize with structural descriptors, and the presence in the best QSRR models of descriptors related to halogen atoms (such as NoF, NoBr, RNoBr, NoI, RNoI, O<sub>I min</sub>) clearly shows that generic descriptors are not suitable for this type of structure–property models.

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Equation		Residual					
	7	21	36	58	140	161	
(36)	91	-30	144	113	-69	-90	
(37)	170	-110	82	77	-73	-108	
(38)	106	-53	153	68	-128	-59	
(39)	126	-73	99	150	-109	-70	
(40)	163	-109	81	83	-63	-101	
(41)	108	-56	132	94	-73	-98	
(42)	100	-52	153	70	-123	-56	
(43)	171	-124	91	48	-115	-81	
(44)	76	-51	153	75	-114	-50	
(45)	71	-54	133	101	-64	-84	

Table 4. The Residual  $(RI_{exp} - RI_{calc})$  for Compounds 7, 21, 36, 58, 140, and 161 Computed with the OSRR Equations (36)–(45)

Since a large and diverse descriptor pool was computed with CODESSA and used in the heuristic MLR procedure for selecting significant structural descriptors, it is of interest to observe that only a small group of them were considered important in estimating the gas chromatographic retention indices of the 207 halogenated compounds from Table 1. As a consequence of this fact, Eqs. (36)–(45) are highly similar and have the origin in Eq. (21) which was obtained with  ${}^{1}\chi^{\nu}$ , NoF, and G<sub>1</sub>. The fourth descriptor comes from the class of charged–partial surface area indices, namely DPSA3<sub>e</sub>, WNSA3<sub>e</sub>, FNSA3<sub>e</sub>, all three computed with atomic charges derived from electronegativity. Similarly with the second descriptor NoF, which counts the F atoms in a compound, the fifth descriptor is related to the count of I or Br atoms (NoBr, RNoBr, NoI, RNoI) or the minimum atomic charge for a I atom, O<sub>I min</sub>. The last descriptor from Eqs. (36)–(45) is either the Randić connectivity index  ${}^{1}\chi$ , the maximum  $\pi$ – $\pi$  bond order BO<sub> $\pi\pi$  max</sub>, or the total molecular two–center resonance energy divided by the number of atoms MTCRE. It is interesting to remark the high relevance of simple structural descriptors in modeling the gas chromatographic retention indices, such as the halogen atom counts, Randić connectivity index  ${}^{1}\chi^{\nu}$ .

# **4 CONCLUSIONS**

A successful application of the CODESSA software system was presented in this study for the prediction of the gas chromatographic retention indexes of 207 halogenated compounds using theoretical descriptors derived from the molecular structure. After a heuristic screening of relevant structural descriptors, we have selected a group of ten QSRR models representing multilinear regression equations with six descriptors. For these QSRR equations the F statistics and leave-oneout cross-validation correlation coefficient have a maximum, compared with those obtained for the MLR models with five and seven structural descriptors. The examination of the QSRR models produced shows that the structural descriptors encode information related to the molecular structure and the interactions that take place between the solute molecules and stationary phase during the gas chromatographic separation process. Different aspects of the molecular structure are encoded into the structural descriptors selected in the QSRR models. A close examination of the structural descriptors selected in the group of MLR equations with six descriptors shows that halogens are difficult to characterize with theoretical descriptors, because the best QSRR models contain each two descriptors related to halogen atoms, namely NoF and one of the following five descriptors related to Br or I atoms: NoBr, RNoBr, NoI, RNoI, and OI min. This situation clearly shows that generic descriptors are not suitable for encoding the halogens effect in gas chromatographic separation process, and considerable efforts should be made in this direction in order to develop better structural descriptors that encode into a proper form the heteroatoms effect. The Randić connectivity index  $\chi^{1}$  is a topological descriptor derived from the molecular graph that encodes the size and degree of branching of the molecules, but do not discriminate between carbon atoms and halogens. The Kier and Hall connectivity index  ${}^{1}\chi^{\nu}$ , derived from the Randić connectivity index  ${}^{1}\chi$ , encodes the size and branching degree and the chemical nature of various chemical species that appear in a hydrogen-depleted molecular graph. The charge-weighted surface area descriptors DPSA3e, WNSA3e, and FNSA3e, all three computed with atomic charges derived from electronegativity, consistently appeared in several QSRR models. This was expected since molecular surface area has been shown to be an important descriptor in modeling the interactions between a compound and the stationary phase during a gas chromatographic separation.

Using the QSRR models proposed in this study, these simple theoretical descriptors can be used to estimate the gas chromatographic retention indices for new compounds in cases where standards are not available. Although the standard error of the estimations is large compared to the experimental uncertainty, the method is useful for investigating regularities in the retention indices and for not yet synthesized halogenated compounds. This is a general problem of QSRR models developed with theoretical descriptors for diverse sets of organic compounds. A significant improvement was recently made by using orthogonal descriptors [8,49], but further investigation is needed to improve the prediction of gas chromatographic retention indices.

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